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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/885,792	06/20/2001	Basanth Jagannathan	FIS920000402US1	4506	
30743	7590 06/04/2003				
WHITHAM, CURTIS & CHRISTOFFERSON, P.C.			EXAMINER		
11491 SUNS SUITE 340	ET HILLS ROAD		LATTIN, CHRI	LATTIN, CHRISTOPHER W	
RESTON, VA	A 20190		ART UNIT	PAPER NUMBER	
			2812		
			DATE MAILED: 06/04/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

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	lacksquare	Application No.	Applicant(s)			
Office Action Summary		09/885,792	JAGANNATHAN ET AL.			
		Examiner	Art Unit			
		Christopher W Lattin	2812			
- The MAILING DATE of this communication appears on the cover sheet with the correspondence address - Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status						
1)⊠	Responsive to communication(s) filed on 5/16	2/03 .				
2a)⊠	•	is action is non-final.		•		
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims					
•	Claim(s) 13-16 is/are pending in the application					
4a) Of the above claim(s) is/are withdrawn from consideration.						
5)	Claim(s) is/are allowed.					
	Claim(s) <u>13-16</u> is/are rejected.			•		
•	7) Claim(s) is/are objected to.					
•	Claim(s) are subject to restriction and/or	r election requirement.				
	on Papers The energification is objected to by the Evamine	•				
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
	1. Certified copies of the priority documents have been received.					
	2. Certified copies of the priority documents have been received in Application No					
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
14)∐ A	cknowledgment is made of a claim for domesti	c priority under 35 U.S.C. § 119	9(e) (to a provisional	application).		
 a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121. 						
Attachmen	•					
2) Notic	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Inform	ary (PTO-413) Paper No(s al Patent Application (PTO			

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 13-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chantre et al. (U.S. Patent 6,177,717) in view of Racanelli (U.S. Patent 6,410,975, previously cited by applicant) and applicant's admitted prior art.

Chantre et al. teach a transistor that has a collector region 60, a SiGe base 81, an emitter stack overlying the collector region, said emitter stack including an emitter opening filled with T-shaped polysilicon 111, said T-shaped polysilicon overlying nitride regions 10 included in said stack, SiGe extrinsic base regions (see Figure 6) arranged on respective sides of said emitter stack, the extrinsic base regions aligned with the polysilicon layer 111, but not directly with the emitter opening contacts, and contacts, but fails to teach that the extrinsic base regions are *directly* aligned with the polysilicon layer or an implanting mask cap on top of the T-shaped polysilicon and no spacers around the emitter. Racanelli teaches a similar bipolar device with extrinsic base regions directly aligned with the polysilicon emitter layer in order to minimize the separation distance between the intrinsic and extrinsic regions. See Racanelli column 2 lines 2-40. It would have been obvious to one skilled in the art at the time of the invention to align the extrinsic base regions directly to the emitter stack in the invention

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of Chantre et al. in order to minimize the separation distance between the intrinsic and extrinsic regions as taught by Racanelli. The prior art of record teaches an implanting mask cap on top of the T-shaped polysilicon, as a well-known means of protecting the structure and no spacers around the emitter. It therefore would have been obvious to one skilled in the art at the time of the invention to form an implanting mask cap on top of the T-shaped polysilicon and no spacers around the emitter as taught by the admitted prior art as a means of protecting the emitter structure and leaving exposed the base regions obviated by Chantre et al. in view of Racanelli.

With reference to claims 13, 14 and 16, Chantre et al. are applied supra and teach all of the limitations of the device and appear to illustrate a longer extrinsic base region and a shorter extrinsic base region. However, it is not clear if a contact is formed on the longer extrinsic base region. The admitted prior art relates a well-known transistor that has a base contact formed on the longer extrinsic base region to form an electrical connection. It therefore would have been obvious to one skilled in the art at the time of the invention to have an electrical contact formed on the longer extrinsic base region.

Response to Arguments

Applicant's arguments filed 5/16/03 have been considered but are not persuasive.

Applicant argues that Racanelli cannot be combined with Chantre et al. because Racanelli is concerned with dopant spiking and not direct alignment. As discussed in

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column 2 of Racanelli beginning at line 17, one object of the method is to reduce the length of the link base region to a minimum. Racanelli does not teach the use of the spacer and in fact encourages against such use by the discussion of the link base region length minimization. Therefore, the references as combined obviate the respective limitations claimed.

Applicant has also amended the claims to include an implanting mask cap on top of the T-shaped polysilicon and no spacers around the emitter. The prior art of record, as illustrated in Figure 1J, teaches an implanting mask cap on top of the T-shaped polysilicon, as a well-known means of protecting the structure and no spacers around the emitter. It therefore would have been obvious to one skilled in the art at the time of the invention to form an implanting mask cap on top of the T-shaped polysilicon and no spacers around the emitter as taught by the admitted prior art as a means of protecting the emitter structure and leaving exposed the base regions obviated by Chantre et al. in view of Racanelli.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within

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TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Christopher Lattin whose telephone number is (703) 305-3017. The examiner can normally be reached Monday through Friday from 8:00 A.M. to 5:00 P.M.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling, can be reached at (703) 308-3325. The fax number for this Group is (703) 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

CWL 6003

y John F. Mebling
Supervisory Patent Examine?
Technology Center 2800